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AF / IRW

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/594,635 Group Art Unit: 1793
Filing Date: September 28, 2006 Examiner: Shuangyi Abu Ali
Applicant: Yoshiharu OHTA et al.
Title: SEMICONDUCTOR POLISHING COMPOSITION (As Amended)
Attorney Docket: 2691-000050/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop AF

Date: December 29, 2009

REQUEST FOR RECONSIDERATION

Sir:

In response to the Office Action mailed August 10, 2009, the shortened statutory period for reply being extended to January 10, 2010 by the attached Extension of Time, the following remarks are respectfully submitted.

A listing of the Claims begin on page 2 of this paper.

Remarks begin on page 4 of this paper.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	12	-	20	=	0
Independent	1	-	3	=	0